Icemos Technology Ltd Product Specification 1900.692502 Issue Date 09 December 2021 08

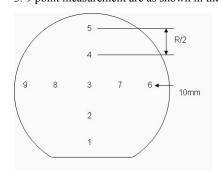
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Part Number	Customer	

Category		Parameter	Specification	Measurement Method
OverallWafer	1.0	Diameter	150.00 +/- 0.30 mm	
	2.0	Primary Flat Orientation	{110}+/-1 degree	Wafer Vendor
	3.0	Primary Flat Length	47.50 +/- 2.50 mm	Wafer Vendor
	4.0	Secondary Flat Orientation	None	
	5.0	Overall Thickness	681.00 +/- 6.00 μm	ADE, 100%
	6.0	Total Thickness Variation (TTV)	<5.00μm	Guaranteed by Process
	7.0	Bow	<80.00μm	ADE to ASTM F534, 20%
	8.0	Warp	<80.00μm	ADE to ASTM F657, 20%
	9.0	Edge Chips	zero as per semi standard (>0.25mm X 0.25mm)	Bright Light, 100% (note 2)
	10.0	Edge Exclusion	7mm	
HandleSilicon	11.0	Handle Growth Method	CZ	Wafer Vendor
	12.0	Handle Orientation	{100} +/- 1 degree	Wafer Vendor
	13.0	Handle Thickness	600.00 +/- 5.00 μm	ADE, 100%
	14.0	Handle Doping Type	N	Wafer Vendor
	15.0	Handle Dopant	Phosphorous	Wafer Vendor
	16.0	Handle Resistivity	1 - 10 Ohmem	Wafer Vendor
	17.0	Backside Finish	Lapped and Etched	Wafer Vendor
BuriedOxide	18.0	Oxide Type	Thermal	
	19.0	Oxide Thickness	20,000.00 +/- 1,000.00 A	Nanospec centre point, 4%
	20.0	Oxide formed on	Device Wafer	
DeviceSilicon	21.0	Device Growth Method	Low Oi CZ	Wafer Vendor
	22.0	Oxygen Concentration	<14.00ppma	New ASTM
	23.0	Device Orientation	{100} +/- 1 degree	Wafer Vendor
	24.0	Nominal Thickness	78.00 +/- 2.00 μm	FTIR, 100% 9-Pt (note3)
	25.0	Distance to device silicon edge from wafer edge	< 5mm	Typical by Process, no edge grind.
	26.0	Edge Removal Depth in Handle	<100um	Typical by process
	27.0	Device Doping Type	N	Wafer Vendor
	28.0	Device Dopant	Phosphorous	Wafer Vendor
	29.0	Device Resistivity	1 - 3 Ohm-cm	Wafer Vendor
	33.0	Voids	0	Bright Light, 100% (note2)
	34.0	Scratches	<25mm total length	Bright Light, 100% (note2)
	35.0	Haze	none	Bright Light, 100% (note2)

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Part Number		Customer		
Category	Parameter	Specification		Measurement Method
Shipping Details	Wafer per box :	Max 25		
	Packaging:	Taped Polypropylene Wafer Box Empak, Ultrapak, 150.00mm Antistatic Double Bagging	ī.	
	Lot Shipment Data	Device Thickness Bow / Warp Data Handle and SOI Thickness		
Explanatory Notes	1. Microscope inspec	tion performed using microscope sca	ın as below. 5x object	tive.
		pections performed exclude all wafer on. High intensity bright lamp inspec	_	

3. 9 point measurement are as shown in the diagram below:



Additional Information